Reldysh and Tratas [6] showed that the comlation of an n-type semiconductor results in the section of the exchange bonds between donor electrops by the electric fields of charged impurity trans. A relative increase in the amplitude of the seperfine splitting lines was observed experimentlity in [7, 8] for n-type compensated silicon. This sheated that localized states were formed.

An analysis of the dependence of the magnitude of the hyperfine splitting of the EPR lines of phoserus in silicon ( $N_D = 7 \cdot 10^{17}$  cm<sup>-3</sup>, K = 99%) on the uniaxial compression can give some information on the interaction of impurities in silicon.

Figure 2 shows the dependence of the relative splitting  $A/A_0$  on the uniaxial compression applied three samples with phosphorus concentrations of  $a_{11} \cdot a_{12} \cdot a_{13} \cdot a_{14} \cdot a_{15} \cdot a_{15}$ 

No theoretical expression is yet available for the influence of the electric fields of charged donors and acceptors on neutral impurities in a semicondactor subjected to uniaxial compression. However, the experimental results (Fig. 1) indicate that the curve for a compensated sample is identical with the curve for a lightly doped crystal, and is shifted from the latter by 4 Oe, which is equal to the difference between the values of the hyperfine splitting at zero pressure. Hence, we may conclude that, in the investigated range of uniaxial compression (up

to 30 kgf/mm<sup>2</sup>), the two causes of the reduction in the hyperfine splitting (uniaxial compression and the Stark effect) are independent.

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